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New Method for Development of Carbon Coated Silica Phases for Liquid Chromatography Part I. Preparation of Carbon Phases

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Abstract

Owing to its combination of unique selectivity and mechanical strength, commercial carbon clad zirconia (C/ZrO₂) has been widely used for many applications, including fast two-dimensional liquid chromatography (2DLC). However, the low surface area available (only 20 - 30 m²/g for commercial porous ZrO₂) limits its retentivity. We have recently addressed this limitation by developing a carbon phase coated on the high surface area of HPLC grade alumina (C/Al₂O₃). This material provides higher retentivity and comparable selectivity, but its use is still limited by how few HPLC quality types of alumina particles (e.g., particle size, surface area, pore size) are available. In this work, we have developed useful carbon phases on silica particles, which are available in various particle sizes, pore sizes and forms of HPLC grade.

To make the carbon phase on silica, we first treat the silica surface with a monolayer or less of metal cations that bind to deprotonated silanols to provide catalytic sites for carbon deposition. After Al (III) treatment, a carbon phase is formed on the silica surface by chemical vapor deposition at 700 °C using hexane as the carbon source. The amount of Al (III) on the surface was varied to assess its effect on carbon deposition, and the carbon loading was varied at different Al (III) levels to assess its effect on the chromatographic properties of the various carbon adsorbents. We observed that use of a concentration of Al (III) corresponding to a full monolayer leads to the most uniform carbon coating. A carbon coating sufficient to cover all the Al (III) sites, required about 4 - 5 monolayers in this work, provided the best chromatographic performance. The resulting carbon phases behave as reversed phases with reasonable efficiency (50,000 – 79,000 plates/meter) for non-aromatic test species.

1. Introduction

Carbonaceous materials are versatile sorbents used in a wide range of applications [1-3]– most particularly, for gas and liquid chromatography (LC) [4,5]. Two commercial carbon phases for LC - carbon clad zirconia (C/ZrO₂) and porous graphitic carbon (Hypercarb) – among all the available reversed-phase materials show unique forms of chromatographic selectivity for polar and nonpolar compounds, as well as for structural isomers, and thus have been used to separate analytes that are not readily resolved by conventional reversed

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phases (e.g. alkyl silica phases) [6-10]. Two review papers describe the advantages of LC carbon phases [11,12].

The unique selectivity of C/ZrO₂, combined with its mechanical strength, make it a promising choice for use in fast two-dimensional liquid chromatography (2DLC) [13], but, as pointed out in a previous study [14], there is a great need to improve its retentivity. We have recently made some progress by developing a promising carbon phase on porous HPLC grade alumina; the resulting material (C/Al₂O₃) showed 4 - 5 fold higher retentivity than did C/ZrO₂, while maintaining the unique selectivity of a carbon-like adsorbent. However, the further development of C/Al₂O₃ is limited by the paucity of available varieties of HPLC grade porous aluminas.

Silica is the most common substrate as a HPLC packing materials and is available in a wide variety of types (e.g. totally porous and superficially porous), pore sizes, surface areas and particle diameters (e.g. sub 2 to greater than 10 μ m) [15]. This variety allows its application in wide array of separations. For example, particularly small particles can be used for fast separations [16,17], whereas superficially porous particles can be used to improve the speed and efficiency of peptide separations [18,19].

Though there have been many attempts to develop carbon phases on silica, none is yet entirely satisfactory for demanding HPLC uses most particularly fast 2DLC. Hypercarb, made from silica 'template' [20] has insufficient mechanical strength [21] and ought not be used above 300 bar. Leboda prepared carbon phases on silica by pyrolyzing organic vapors such as dichloromethane [22]; Kamegawa and Yoshida pre-coated silica with a crosslinked polymer layer and subsequently pyrolyzed the polymer layer [23]; and Engel *et al.* pre-adsorbed diethynyl aromatic oligomers on silica and subsequently pyrolyzed the oligomers [24]. However, these were either unsuitable for HPLC or exhibited both low efficiencies and significantly tailed peak shapes when used for chromatography.

Leboda *et al.* made the significant observation, though, that treatment of the silica surface with other metals can assist carbon deposition. They impregnated silica with nickel (II) and zirconium (IV) salts to catalyze the decomposition of hydrocarbons on silica [25,26]; unfortunately, the high metal loading used caused a significant loss of surface area. In addition, deposition of the metal by impregnation can lead to uncontrolled precipitation and crystallization of the metal oxide and hydroxides [27], which can cause pore blockage. Thus, we needed to develop a method to put metals on silica in a regulated manner, if possible limiting treatment to a monolayer of metal, prior to carbon deposition by CVD.

In this paper, we present such a method to prepare metal-treated silica as a substrate for the development of carbon phases for use as HPLC media. Unlike Leboda's method of deposition, we use the electrostatic binding between positively charged metal ions and deprotonated silanol groups, so we are able to limit the amount of metal to a monolayer or less. Adapting a method previously very widely used to bring about homogeneous precipitation of metallic compounds [28], we used the slow hydrolysis of urea in solution to homogeneously raise the pH so slowly that all cations adsorb onto the silica surface, thereby avoiding self-oligomerization and precipitation [29]. Moreover, unlike Leboda's method, we chose to try Al (III) - a metal well known to produce on silica reactive sites that can produce carbon coatings ("coke" that can deactivate solid acid catalysts).

After treatment with Al (III), a carbon phase is formed on the surface by chemical vapor deposition (CVD). The amount of Al (III) was varied to assess its effect on carbon deposition. The carbon loading was varied by adjusting the reaction time on each substrate. Each carbon-clad Al (III) doped silica, here after denoted C/Al/SiO₂, material was then

packed into a column to evaluate chromatographic performance including efficiency and retentivity.

2. Experimental

2.1. Chemicals

HPLC grade hexanes from Sigma – Aldrich (St. Louis, MO, USA) were used as the CVD carbon source. All chemicals used for the chromatographic study were obtained reagent grade or better from Sigma-Aldrich (St. Louis, MO, USA). HPLC eluents were HPLC grade acetonitrile from Burdick and Jackson (Muskegon, MI, USA) and HPLC grade water (18.2 M Ω) that was prepared in-house from a Barnstead Nanopure II deionizing system (Dubuque, IA, USA). Prior to use, this water was boiled to remove carbon dioxide and passed through a 0.45 µm nylon filtration apparatus (Lida Manufacturing Inc., Kenosha, WI, USA).

2.2. Preparation of metal adsorbed silica

2.2.1. Materials—Aluminum chloride hexahydrate (Fisher Scientific, Fair Lawn, NJ, USA) was used for the Al (III) treatment. Silica, 13.7 μm AstroSil (Stellar Phases Inc, Yardley, PA, USA) was used for the preliminary CVD study with Al (III) metal-treatments, and 5 μm Zorbax silica (Agilent Technologies, Palo Alto, CA) was used to prepare HPLC supports with Al (III) treatment.

For comparison, attempts were also made with Leboda's choice of Zr (IV) using zirconium tetrachloride (Sigma-Aldrich, St. Louis, MO USA), but we found Al (III) much more effective for carbon deposition.

 C/ZrO_2 (3 µm, carbon loading = 8 %, w/w), used for comparison, was a generous gift of ZirChrom Separations Inc. (Anoka, MN, USA).

2.2.2. Procedure for metal adsorption—The amount of metal chloride to be added was based on the surface area of silica measured by N_2 adsorption and the assumption that there are about 8 µmol/m² silanol groups on the silica surface and that Al (III) would react with them in 1:1 ratio. The initial solution was strongly acidic (pH ~ 1, 0.1 mol/L HCl) to avoid oligomerization of metal cations and to ensure that silanol groups were not dissociated and some were positively charged. A large volume of solution was used to keep the metal concentration low (10 – 40 mmol/L) again to discourage oligomerization as the pH is raised. The silica slurry in 0.1 mol/L hydrochloric acid solution was prepared at 0.025 % (w/v) by magnetically stirring in round-bottomed flask to suspend the particles and then sonicating for 15 min to remove air from the pores of the silica. Then, the first half of the hydrochloric acid solution with the requisite amount of aluminum chloride dissolved in it was slowly added in the center of the vortex. Finally, an excess of urea (0.5 mol/L) was added. The solution was rigorously stirred over the whole procedure.

The initial pH of the solution was 1 - 1.2 at 25 °C. The solution is heated to boiling under reflux. Urea in the solution converts slowly to ammonia, producing a slow and homogeneous increase of the pH. This slow and well-mixed pH change, combined with the ample availability of negatively charged deprotonated silanols on the high surface area silica, prevents the buildup of dissolved metal species that are prone to oligomerization; this oligomerization could nucleate independent particles or, even worse, block pores in the silica. The reaction was stopped (~ 2 h) as the pH reached 4 - 4.3 at 100 °C. The slurry was quickly cooled to room temperature in an ice bath. After filtering the solution, it was washed

with water (HPLC grade), and the particles were dried in a vacuum oven overnight at 100 $^\circ\text{C}.$

2.3. Colorimetric titration and metal analysis

Metal-treated silica underwent elemental analysis by ICP OES (Geology Department, University of Minnesota). An indirect colorimetric titration method was used to determine the residual Al (III) in the suspending solution after the reaction; this method is described thoroughly elsewhere [30], but it is worthwhile here to review the key steps. An excess of EDTA (0.01 mo/L) is added to an Al (III) solution, and the excess EDTA is titrated by 0.01 mol/L Pb(NO₃)₂ using xylenol orange as an indicator. About 5 % error in quantitation of Al (III) was obtained based on the triplicate trials of the titration of a standard Al (III) solution (0.005 mol/L in 0.25 mol/L HCl). Subsequently, titration of the filtered solution remaining after Al (III) treatment of silica showed that less than 5 % of the Al (III) provided remained in solution. Except where noted, these results, as well as the ICP OES results, confirm that the Al (III) is quantitatively adsorbed onto the silica surface.

2.4. Carbon deposition

Chemical vapor deposition (CVD) was used to deposit carbon on the metal-treated silicas. The apparatus and process are described in detail elsewhere [14]. The CVD was conducted at 700 °C for 6 h or more using hexanes (thermostated at 0 °C) as a carbon source. After each batch, the resulting material was sent to Atlantic Microlabs (Norcross, GA, USA) for the determination of its carbon content).

2.5. Column packing

The carbon packing material made here, and the C/ZrO_2 commercial materials, were packed by the same procedures described elsewhere [13].

2.6. Chromatographic studies

All chromatographic data were collected by using an HP 1090 LC system controlled by Chemstation software version A.10.01 (Agilent Technologies, Wilmington, DE, USA) and equipped with an autosampler, thermostatting column compartment and photodiode array UV detector. All solutes were detected at 210 nm. Column dead times were measured from retention time of acetone. All retention data given represent averages of triplicate runs.

2.7. Conductivity measurement and N₂ adsorption

The electrical conductivity of the carbon material was examined using the circuit as we described previously [14]. Nitrogen sorption was measured using a Micromeritics ASAP 2000 sorptometer (Micromeritics, Norcross, GA); the specific surface area was computed using the BET method [31], and pore size distributions were approximated using the BJH method [32].

3. Results and discussion

3.1. Different amounts of AI (III)

We treated 5 μ m (Zorbax) silica particles with various amounts of Al (III) (2, 4 and 8 μ m/m²). Assuming 8 μ mol/m² of silanol group as one monolayer these represent roughly quarter-, half- and full- monolayer coverages of Al (III).

We also attempted to prepare a surface coated with 12 μ mol/m², but this resulted in precipitation due to the presence of excess (non-adsorbed) Al (III) in solution when the pH reached values of 4.1. Modifying the treatment conditions by stopping the treatment at a

lower final pH, *i.e.* 3.8 at 100 °C prevented nucleation of the excess Al (III) in the solution, but titration of the final solution showed excess Al (III) in the solution and indicated that only about 10 μ mol/m² had adsorbed on the surface of silica. Since attempting such a high surface loading of Al (III) fails to allow quantitative adsorption and risks the formation of oligomerized species, which could plug pores or nucleate new particles, we limited our chromatographic study to 8 μ mol/m² (a full monolayer) as the maximum amount of Al (III) treatment.

3.2. Effect of AI (III) treatment on pore structures

It is desirable to maintain the pore structure of silica after metal deposition. To confirm that Al (III) treatment did not affect the pore structure (i.e., that no oligomerization or precipitation of aluminum hydroxide plugged the pores) we conducted nitrogen sorptometry to monitor the effect of different amount of Al (III) treatment (4 and 8 μ mol/m²) on the pore structure of silica. The surface area, pore volume and the average pore diameter show that the silica treated with 8 μ mol/m² of Al (III) lost only 10 % of its surface area and 14 % of its pore volume, which is a reasonable loss as compared to the estimated volume decrease based on the assumption of density of aluminum hydroxide (2.4 g/cm³). Compared to Leboda's result of the loss of 40 % of the surface area after putting Zr (IV) on silica [26], our method maintains a high surface area. In addition, the estimated pore size distributions in Fig. 1 show that the original pore structure of silica is well-maintained after the Al (III) treatment.

3.3. Effect of AI (III) treatment on carbon deposition

Carbon was deposited on both quarter- and full-monolayer Al (III) treated silicas, and the carbon load was adjusted by varying the reaction time. Both substrates showed increases in the carbon load with the time, but the increase is much faster with a full monolayer of Al (III). Fig. 2 compares the rate of carbon deposition on these substrates and on alumina. Evidently, the substrate with more Al (III) allows the carbon to deposit faster, though it is still slower than that of alumina. Moreover, on the silica treated with full-monolayer Al (III) carbon deposits with time in a manner more similar to alumina than to silica covered with the quarter-monolayer Al (III). Finally, Fig. 2 shows that there is a considerable change in the rate of deposition of carbon at short time.

The 2 μ mol/m² of Al (III) treated silica requires about 32 % carbon to fully cover the Al (III) layer; the 8 μ mol/m² of Al (III) treated silica requires about 25 % carbon. We hypothesize that the latter has more uniform coating and thus less is required to sequester the Al (III). We did not go beyond these carbon loadings; these carbon loadings should give maximum retentivity [14].

3.4. Repeatability of the various preparations of carbon phases

Table 1 summarizes the repeatability of the chromatographic properties of several preparations of carbon phases deposited on 2 μ mol/m² of Al (III) treated silica (C/2 μ molAl/SiO₂). Three identical deposition runs gave an average of 30.6 % (w/w) of carbon with only 3 % standard deviation. The resulting materials were packed and evaluated by measuring the chromatographic efficiency and retention of nitrohexane, toluene and nitrobenzene. As shown in Table 1, this carbon phase gave reproducible efficiency (8 % RSD) and retention (7 – 12 % RSD). The plate count was obtained from nitrohexane as it provides the maximum value and the least peak tailing. Fig. 3 shows the chromatogram of a homolog series of nitroalkanes. We had to put about 32 % (w/w) of carbon for the final product because this loading provided both the maximum retentivity and full sequestration of the Al (III) sites on silica; this was ascertained by used of benzoic acid as a probe for accessible Al (III) as per the method of Trammell *et al.* [33]. For the same reasons, we finally deposited about 25 %

(w/w) of carbon on 8 μ mol/m² of Al (III) treated silica. A chromatogram of the nitroalkanes on this material is shown in Fig. 3. This carbon phase gives higher efficiency (79,000 plate counts/m) than does 32 % C/2 μ molAl/SiO₂. The reasonably good efficiency and peak shapes of nitroalkanes suggest that all these carbon phases are potentially useful as HPLC packing materials.

3.5. Chromatographic characteristics

We expected based on our previous results for carbon deposited on alumina that the C/Al/ SiO₂ should behave as a reversed phase. To confirm this, we plotted log k vs. the number of methylene groups (n_{CH_2}) for a homolog series of nitroalkanes (see Fig. 4). Reversed phase behavior is clearly demonstrated by linear increase of log k with the number of methylene group. It seems that one monolayer of carbon (*ca.* 8 %) is sufficient to convert silica to a reversed phase, but the retentivity of this material remains very low. As discussed below, we believe this must be due to the non-uniformity of the carbon cladding; more carbon is apparently needed to achieve a homogeneous outer layer of cladding.

From the slopes, we calculated the free energy of transfer per methylene group from the mobile to the carbon phase ($\Delta G_{CH_2} = -2.3BRT$; B is the slope of the line in Fig. 4, R is gas constant and T is the temperature) [34]. As listed in Table 2, the free energy of transfer allows a quantitative comparison of the affinity of carbon phases to methylene groups. The affinity increases as we deposit more carbon on both Al (III) treated silicas. Table 2 indicates that with the exception of the 8 % C/2µmolAl/SiO₂ the different C/Al/SiO₂ materials are very similar in terms of both the slope and intercept. The slope of the 24 % C/ Al_2O_3 phase is clearly different although it has similar number of carbon layers (5 monolayers) as the 32 % and 25 % C/Al/SiO₂ (4 – 5 monolayers). We have no explanation for these small differences in slope. They could easily result from different degrees of oxidation during synthesis or perhaps to residual effects of the underlying substrate on retention. In fact, spectroscopic characterization (XPS and FT-IR) in the previous work did not detect any chemical difference of carbon between C/Al₂O₃ and C/ZrO₂, which showed bigger difference in the slope of log k vs n_{CH2}. As compared to the conventional octadecyl bonded silica (ODS) phase, all carbon phases exhibit higher slopes, thus stronger affinity for methylene groups. This is consistent with the observation that carbon phases give greater selectivity for a methylene group than do ODS phases [21].

As shown in both Fig. 4 and 5, retentivity of C/Al/SiO₂ for all polar and nonpolar compounds used increases with increasing carbon loads on both substrates. This implies that increase of surface coverage by carbon with higher carbon loads since bare Al/SiO₂ surface does not retain these compounds. Interestingly, the pattern of the increase in retentivity, thus covering the surface with carbon is very different between 2 and 8 μ molAl/SiO₂ (see Fig. 5). The retention of all compounds increases almost linearly (R² of at least 0.990) with % C on the high Al/SiO₂ with a statistically zero or nearly-zero (~ 0.2) intercept based on least squares analysis. However, the increase is not constant with carbon loads on the low Al/SiO₂ showing non-zero intercept suggesting that a minimum amount of carbon is required before retention can be achieved. This comparison suggests that the surface is covered by the carbon more efficiently on the high Al/SiO₂, which may induce carbon deposition more uniformly on the surface than the low Al/SiO₂.

3.6. Physical characteristics

Pore size distribution—Table 3 summarizes the pore parameters for materials made with different carbon loads. Both the surface areas and pore volumes decrease upon increasing the carbon load. However, the area loss per % C is much less when a higher amount of Al (III) is coated on the silica; the silica with 8 μ mol/m² Al (III) loses ~ 1.5 m²/g per % C,

compared to ~ 3.5 m²/g per % C on the silica with only 2 μ mol/m² Al (III). We infer that the higher Al (III) treatment induces a more efficient and uniform carbon deposition, which is consistent with the observation that higher retentivity is achieved with lower carbon loading on 8 μ mol/m² of Al (III) treated silica.

Neither substrate gave an absolutely uniform carbon deposition; both require much more than a theoretical monolayer of carbon to achieve maximum retentivity. Assuming that the carbon is graphitic and coated uniformly, we calculated the number of carbon monolayers from the BET data and the known weight of the carbon for each material as shown in Table 3. Theoretically, the % C required to form one monolayer is about 7 % (w/w). However, as mentioned above, about 32 % and 25 % of carbon are needed for the low and high levels of Al (III) treatments of silica respectively to obtain maximum retentivity and to fully sequester the Al (III) sites on the silica. These carbon loads correspond to about 4-5 carbon monolayers which strongly suggests that carbon deposition is not homogeneous. That is, we believe that carbon deposition does not proceed monolayer by monolayer, which is, in fact, commonly observed from deposition of pyrolytic carbon [35]. However, this result is rather similar to the number of monolayers we had to put on alumina for its full coverage of the substrate. It should also be noted that the C/ZrO₂ required about 8 % (w/w) of carbon to ensure complete coating of the surface so that all solute access to the ZrO₂ substrate was blocked; this is equivalent to about 11 monolayers of carbon on this low surface area material.

To estimate the pore size distributions, pore area and volume distributions curves based on nitrogen adsorption and desorption were computed using the BJH method. As shown in Fig. 6, different levels of Al (III) on silica surface induce carbon deposition in a very different fashion. It is possible that when too little Al (III) is used, carbon forms with a significant induction delay (see Fig. 2) and in a "patchier" manner, leaving uncoated Al/SiO₂ surface. When a monolayer of Al (III) is used, carbon is deposited without so much induction delay, and with a more uniform covering of the surface. This cladding must still be rough enough, though, to produce a texture that shows up as new area with a small apparent pore size; these new small pores may just be the nanoscale texture of the rough, but uniform, carbon coating.

Resistivity—The resistivities of the carbon materials on different substrates are compared in Table 4. The materials include graphite and carbon phases on the various oxides. Since carbon is conductive and silica is not, we expect that those materials with a lower fraction of silica covered by carbon will have higher resistivity due to less continuous carbon layers. Both materials studied here have as low a resistivity as that of carbon on alumina. As these carbon coated materials have about the same number of carbon monolayers and are prepared at the same temperature, this result implies a high coverage of the silica by carbon. It should be noted that the 25 % carbon loaded material shows resistance comparable to 32 % carbon, which may again suggest a more efficient carbon deposition on the high Al (III) treated silica. The similarity in the resistivity of these carbon clad materials to that of graphite indicates a considerable degree of sp² hybridization of the carbon. Low resistivity also implies high polarizability of carbon surface, which should enhance retentivity [24].

4. Conclusion

A novel method is proposed to activate silica with metals for the deposition of a carbon surface for use as a liquid chromatographic media. Al (III) (≤ 1 monolayer), the most effective metal in our hands, is chemically adsorbed on silica by interaction with deprotonated silanol groups on the surface of silica. By adapting a method previously used to induce homogeneous precipitation, we used the slow hydrolysis of urea to homogeneously generate metal hydroxides during the reaction. All Al (III) added to solution

was fully adsorbed on the silica surface as confirmed by titration of the filtered solution and by ICP OES analysis of the particles. Unlike Leboda's methods, the present method provides a thin, uniform film of metallic species on silica as shown by the insignificant changes in pore structure upon deposition of the metallic species.

Subsequently, a carbon phase is formed on the Al (III) treated silica by high temperature chemical vapor deposition (CVD). Carbon deposition is more efficient and uniform when a full monolayer rather than a quarter monolayer of Al (III) is pre-deposited on the silica. In terms of its carbon deposition properties the more heavily Al (III) coated silica behaves more similarly to pure alumina than does the lightly clad material. The best chromatographic stationary phases were obtained with about 32 % and 25 % carbon on the quarter and one monolayer of Al (III) clad silica, respectively. The resulting carbon materials offer good chromatographic efficiency and can be prepared reproducibly (3 % standard deviation). These new carbon phases behave as reversed phases and provide higher retentivity than does C/ZrO_2 . Further chromatographic characterization of these materials will be presented in subsequent work. However, given the chromatographic data, these new carbon stationary phases are very useful as HPLC packing materials. Considering the wide variety of sizes and types of silica available, our new method shows potential to developing various types of carbonaceous materials for HPLC supports.

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References

- 1. Cserhati T. Biomed Chromatogr. 2009; 23:111. [PubMed: 19137510]
- 2. Di Corcia A, Samperi R, Marcomini A, Stelluto S. Anal Chem. 1993; 65:907.
- 3. Guenu S, Hennion MC. J Chromatogr A. 1994; 665:243.
- 4. Di Corcia A, Liberti A, Sambucini C, Samperi R. J Chromatogr. 1978; 152:63.
- 5. Tanaka N, Tanigawa T, Kimata K, Hosoya K, Arai T. J Chromatogr. 1991; 549:29.
- 6. Barrett DA, Pawula M, Knaggs RD, Shaw PN. Chromatographia. 1998; 47:667.
- 7. Forgacs E, Cserhati T. Chromatographia. 1992; 33:356.
- 8. Forgacs E, Cserhati T, Pharm J. Biomed Anal. 1998; 18:15.
- 9. Jackson PT, Kim T-Y, Carr PW. Anal Chem. 1997; 69:5011. [PubMed: 9414615]
- 10. Weber TP, Carr PW. Anal Chem. 1990; 62:2620.
- 11. Knox JH, Ross P. Adv Chromatogr (N Y). 1997; 37:73.
- 12. Unger KK. Anal Chem. 1983; 55:361A.
- 13. Stoll DR, Cohen JD, Carr PW. J Chromatogr A. 2006; 1122:123. [PubMed: 16720027]
- 14. Paek C, Carr PW, McCormick AV. J Chromatogr A. 2010; 1217:6475. [PubMed: 20850126]
 - 15. Majors RE. LCGC North Am. 2009; 27:956.
 - 16. Knox JH, Saleem M. J Chromatogr Sci. 1969; 7:614.
 - 17. Poppe H. J Chromatogr A. 1997; 778:3.
 - Kirkland JJ, Truszkowski FA, Dilks CH, Engel GS. J Chromatogr A. 2000; 890:3. [PubMed: 10976789]
 - 19. Wang X, Barber WE, Carr PW. J Chromatogr A. 2006; 1107:139. [PubMed: 16412451]
 - 20. Knox JH, Kaur B, Millward GR. J Chromatogr. 1986; 352:3.
- 21. Weber TP, Jackson PT, Carr PW. Anal Chem. 1995; 67:3042.
- 22. Leboda R. Chromatographia. 1981; 14:524.
- 23. Kamegawa K, Yoshida H. J Colloid Interface Sci. 1993; 159:324.

- 24. Engel TM, Olesik SV, Callstrom MR, Diener M. Anal Chem. 1993; 65:3691.
- 25. Gierak A, Leboda R. J Chromatogr A. 1989; 483:197.
- 26. Leboda R, Gierak A, Hubicki Z, Lodyga A. Mater Chem Phys. 1991; 30:83.
- 27. Kung HH, Ko EI. Chem Eng J. 1996; 64:203.
- 28. Laitinen, HA. Chemical Analysis. New York: 1960. p. 138
- 29. Aiken B, Hsu WP, Matijevic E. J Mater Sci. 1990; 25:1886.
- 30. Langmyhr FJ, Kritiansen H. Anal Chim Acta. 1959; 20:524.
- 31. Brunauer S, Emmett PH, Teller E. J Am Chem Soc. 1938; 60:309.
- 32. Barrett EP, Joyner LG, Halenda PP. J Am Chem Soc. 1951; 73:373.
- 33. Trammell BC, Hillmyer MA, Carr PW. Anal Chem. 2001; 73:3323. [PubMed: 11476232]
- 34. Melander WR, Horvath C. Chromatographia. 1982; 15:86.
- 35. Bourrat X, Langlais F, Chollon G, Vignoles GL, Braz J. Chem Soc. 2006; 17:1090.



Figure 1.

Differential pore size distributions for pore volume and surface area for various carbon loads computed by the BJH method from nitrogen adsorption (upper) and desorption (lower) data. (*) SiO₂; (\diamond) half monolayer (4 µmol/m²) Al/SiO₂; (\diamond) one monolayer (8 µmol/m²) Al/SiO₂.



Figure 2.

Plot of carbon loading (% C, w/w) vs. CVD time for alumina (\diamondsuit), 8 µmolAl/SiO₂ (\triangle) and 2 µmolAl/SiO₂ (\circ). The arrow is to help compare induction times between 8 µmolAl/SiO₂ and 2 µmolAl/SiO₂. CVD temperature is 700 °C for all data.



Figure 3.

Chromatogram for homolog series of nitroalkanes (nitropropane, nitrobutane, nitropentane and nitrohexane). LC conditions: 20/80 MeCN/water, T = 40 °C, F = 0.4 ml/min. 33×2.1 mm id. column for both phases.



Figure 4.

Plot of log k vs. number of methylene groups for nitroalkane homologs (nitropropane, nitrobutane, nitropentane and nitrohexane). (a) 2 μ molAl/SiO₂: (\blacktriangle) 32 %; (\Box) 8 % C; (b) 8 μ molAl/SiO₂: (\triangle) 25 %; (\Box) 21 %; (\diamondsuit)14 % C; (\circ) C/ZrO₂.; (*), 24 % C/Al₂O₃. LC conditions: F = 0.4 ml/min., T = 40 °C, 35/65 MeCN/water; all columns are 33 × 2.1 mm id. Error bars are not bigger than the markers in the plot.



Figure 5.

Plot of k vs. % C (w/w) for nitrobenzene ($\mathbf{\nabla}$), p-xylene ($\mathbf{\Phi}$), ethylbenzene ($\mathbf{\bullet}$) and toluene ($\mathbf{\bullet}$). A: 2µmolAl/SiO₂; B: 8 µmolAl/SiO₂, Extrapolation in B is based on linear regression of all data points (R² for nitrobenzene, p-xylene, ethylbenzene and toluene are 0.990, 0.999, 0.999 and 0.999, respectively). LC conditions: F = 0.4 ml/min., T = 40 °C, 50/50 MeCN/ water; all columns are 33 × 2.1 mm id. Error bars are not bigger than the markers in the plot.



Figure 6.

a.Differential pore volume and area distributions for various carbon loads on 2 μ molAl/SiO₂ computed by the BJH method from nitrogen adsorption (upper) and desorption (lower). (*) bare SiO₂; (\diamondsuit) 8 % C; (\circ) 32 % C.

b.Differential pore volume and area distributions for various carbon loads on 8 µmolAl/SiO₂; adsorption (upper) and desorption (lower); (*) bare 8 µmolAl/SiO₂; (\Box) 21 % C; (Δ) 25 % C.

Table 1

Repeatability of the carbon deposition process

%C(w/w) a 31.6 29.5 30.7 30.6 3 Plate count/m b $45,800$ $46,300$ $52,400$ $48,200$ 8 Symmetry c 0.6 0.6 0.6 0.6 3 k of nitrohexane d 5.9 4.9 4.9 5.2 11 k of toluene e 1.3 1.4 1.5 1.4 7 k of toluene e 1.3 1.4 1.5 1.4 7		Batch 1	Batch 2	Batch 3	Average	%RSD
Plate count/m b 45,800 46,300 52,400 48,200 8 Symmetry c 0.6 0.6 0.6 0.6 3 k of nitrohexane d 5.9 4.9 4.9 5.2 11 k of toluene e 1.3 1.4 1.5 1.4 7	%C (w/w) <i>a</i>	31.6	29.5	30.7	30.6	3
Symmetry c 0.6 0.6 0.6 0.6 3 k of nitrohexane d 5.9 4.9 4.9 5.2 11 k of toluene e 1.3 1.4 1.5 1.4 7 V of nitrohexane e 4.9 3.9 4.7 4.5 12	Plate count/m b	45,800	46,300	52,400	48,200	8
k of nitrohexane d 5.9 4.9 4.9 5.2 11 k of toluene e 1.3 1.4 1.5 1.4 7	Symmetry ^c	0.6	0.6	0.6	0.6	ю
k of toluene e 1.3 1.4 1.5 1.4 7 V of vitrobarrance 4.9 3.9 4.7 4.5 12	k of nitrohexane d	5.9	4.9	4.9	5.2	11
¹	k of toluene e	1.3	1.4	1.5	1.4	٢
	k of nitrobenzene e	4.9	3.9	4.7	4.5	12
	Plate count from nitro	hexane.				
Plate count from nitrohexane.	Symmetry based on n	itrohexane,	LC conditi	ons: $F = 0.4$	t ml/min., T	= 40 °C,
Plate count from nitrohexane. Symmetry based on nitrohexane, LC conditions: F = 0.4 ml/min., T = 40 °C	l 35/65 MeCN/water,					

 e 50/50 MeCN/water; All packed in 33 \times 2.1 mm id. column.

Table 2

The slopes, intercept and ΔG_{CH2}^{a} obtained from different carbon phases

Materials	Slope (B)	Intercept	R ²	$\Delta G_{CH_2}(cal/mol)^{\mathcal{C}}$
ODS ^b	$0.301_{\pm0.001}$	$-0.712_{\pm 0.003}$	0.999999	$-431_{\pm 1}$
C/ZrO ₂	$0.322_{\pm0.002}$	$-1.349_{\pm 0.003}$	0.99995	$-461_{\pm 3}$
24 % C/Al ₂ O ₃ ^c	$0.376_{\pm0.003}$	$-1.02_{\pm 0.01}$	0.99986	-538 _{±4}
8 % C/2µmolAl/SiO ₂	$0.305_{\pm0.001}$	$-1.49_{\pm 0.01}$	0.99986	-437 _{±1}
32 % C/2µmolAl/SiO ₂	$0.350_{\pm0.002}$	$-1.33_{\pm 0.01}$	0.99986	-501 _{±3}
14 % C/8µmolAl/SiO ₂	$0.332_{\pm0.002}$	$-1.34_{\pm 0.01}$	0.99990	-475 _{±3}
21 % C/8µmolAl/SiO ₂	$0.338_{\pm0.002}$	$-1.24_{\pm 0.01}$	0.99987	-484 _{±3}
25 % C/8µmolAl/SiO ₂	$0.339_{\pm0.002}$	$-1.21_{\pm 0.01}$	0.99986	-486 _{±3}

 a The free energy of transfer per methylene group based on nitroalkane homolog series. (See Fig. 4 for LC conditions)

 b Zorbax SB C18, uracil used for dead volume measurement, 50 \times 2.1 mm id. Column

^cData obtained from ref 14.

 $^d{\rm The}$ slope and intercept of the linear regression of log k' vs. n ${\rm CH}_2$

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Characteristics of different carbon loads on Al/SiO₂

CVD condition	%C (w/w)	Carbon ^a (μmol/m ²)	Hypothetical carbon thickness b (monolayers)	S _{BET} ^c (m ² /g)	Pore volume ^d (cm ³ /g)	Nominal BET pore diameter ^d (nm)
SiO ₂	n/a	n/a	n/a	211	0.79	15.0
$2 \mu molAl/SiO_2$	n/a	n/a	n/a	<i>f</i>	ı	ı
700 °C 6h	8	30	1.1	183	0.64	14.0
700 °C 16h	32	125	4.8	115	0.33	11.3
8µmolAl/SiO2	n/a	n/a	n/a	180	0.68	15.1
700 °C 6h	14	67	2.5	ı	ı	
700 °C 8h	21	98	3.7	149	0.47	12.6
700 °C 11h	25	144	4.4	147	0.43	11.7
<i>a</i> , <i>b</i> See ref 14.						
$^c{ m Surface}$ area (SBE	3T)					
$d_{ m Pore \ volume \ obtai}$	ined from sing	le total pore volume less	than 217, 254, 222, 131, 386, 123 nm diameter at <i>l</i>	⁰ /P ₀ of 0.991, 0.9	92, 0.991, 0.985, 0.995 an	d 0.984, respectively (from top to bottom)
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(m

 e Nominal pore diameter of an equivalent single cylinder, calculated by 4x (pore volume)/SBET.

 $f_{\rm AS}$ 4 and 8 µmol Al/SiO2 hardly affect the original pore structure of SiO2, we did not obtain the data for 2 µmolAl/SiO2.

Table 4

Electrical resistance of various carbon materials^a

Materials	Log (resistance, $\Omega)^b$
32 % C/Al/SiO ₂	$2.6{\scriptstyle~\pm 0.1}$
25 % C/Al/SiO ₂	$1.9 \scriptstyle \pm 0.1$
24 % C/Al ₂ O ₃	$2.12 \scriptstyle \pm 0.07$
C/ZrO ₂	$3.35_{~\pm~0.08}$
Graphite	$2.20{\scriptstyle~\pm 0.05}$

 a See ref. 14 for the calculation of the resistance

^bAverage of triplicate measurement